

L Number	Hits	Search Text	DB	Time stamp
27	5	("4232327" "4728617" "5100810" "5292675" "5508209").PN.	USPAT	2003/01/06 09:43
28	12	("4394737" "4739399" "4755681" "4969043" "5081346" "5129028" "5138166" "5138642" "5150394" "5259057" "5308986" "5391879").PN.	USPAT	2003/01/06 09:44
33	11	("4234358" "4379020" "4498951" "4559102" "4581620" "4599133" "4612072" "4657603" "4670086" "4843031" "5103284").PN.	USPAT	2003/01/06 09:46
34	11	("4234358" "4379020" "4498951" "4559102" "4581620" "4599133" "4612072" "4657603" "4670086" "4843031" "5103284").PN.	USPAT	2003/01/06 09:47
35	12	("4394737" "4739399" "4755681" "4969043" "5081346" "5129028" "5138166" "5138642" "5150394" "5259057" "5308986" "5391879").PN.	USPAT	2003/01/06 09:50
38	5	("4232327" "4728617" "5100810" "5292675" "5508209").PN.	USPAT	2003/01/06 09:51
39	5	((("6265745") or ("5953597") or ("6337935"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/06 10:06
40	8	("4409724" "5145808" "5313076" "5504020" "5523257" "5580801" "5608232" "5712191").PN.	USPAT	2003/01/06 10:01
41	2	("6204099").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/06 10:06
42	69	("3848104" "4046618" "4059461" "4083272" "4160263" "4234358" "4249960" "4309225" "4328553" "4341569" "4370175" "4409724" "4439245" "4463028" "4468551" "4469551" "4545823" "4734550" "4764485" "4803528" "4835704" "4862227" "4937618" "4956549" "4970366" "5145808" "5217921" "5219786" "5221365" "5313076" "5352291" "5372836" "5413958" "5424244" "5448582" "5477073" "5504020" "5508209" "5523257" "5543636" "5561081" "5576556" "5578520" "5580801" "5608232" "5608251" "5612251" "5622814" "5623157" "5643801" "5648277" "5681759" "5696003" "5708252" "5712191" "5719065" "5739549" "5756364" "5804878" "5891764" "5891766" "5939731" "5943354" "5945711" "5953597" "5956105" "5962869" "5962872" "5962897").PN.	USPAT	2003/01/06 10:06
	2	"20010045563"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:11
	3	((("6265745") or ("5953597"))).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:23

70	"3848104" "4046618" "4059461" "4083272" "4160263" "4234358" "4249960" "4309225" "4328553" "4341569" "4370175" "4409724" "4439245" "4463028" "4468551" "4469551" "4545823" "4734550" "4764485" "4803528" "4835704" "4862227" "4937618" "4956549" "4970366" "5145808" "5217921" "5219786" "5221365" "5313076" "5352291" "5372836" "5413958" "5424244" "5448582" "5477073" "5504020" "5508209" "5523257" "5543636" "5561081" "5576556" "5578520" "5580801" "5608232" "5608251" "5612251" "5622814" "5623157" "5643801" "5648277" "5681759" "5696003" "5708252" "5712191" "5719065" "5739549" "5756364" "5804878" "5821138" "5891764" "5891766" "5939731" "5943354" "5945711" "5953597" "5956105" "5962869" "5962872" "5962897").PN.	USPAT	2002/10/31 09:52
8	("4409724" "5145808" "5313076" "5504020" "5523257" "5580801" "5608232" "5712191").PN.	USPAT	2002/10/31 09:58
6	("4177372" "4330363" "4406709" "5403772" "5488000" "5591668").PN.	USPAT	2002/10/31 09:59
5	("5147826" "5275851" "5318661" "5403772" "5426064").PN.	USPAT	2002/10/31 10:12
180	tft and (a-silicon amorphous-silicon)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:25
64	(tft and (a-silicon amorphous-silicon)) and irradiat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:31
47	((tft and (a-silicon amorphous-silicon)) and irradiat\$4) and laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:26
0	((tft and (a-silicon amorphous-silicon)) and irradiat\$4) and(cw adj laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:26
35	((((tft and (a-silicon amorphous-silicon)) and irradiat\$4) and laser) and (hydrogen halogen))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:27
28	((((tft and (a-silicon amorphous-silicon)) and irradiat\$4) and laser) and (hydrogen halogen)) and (carbon c) and (nitrogen n) and (oxygen o)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 10:30
27937	(amorphous adj silicon) and substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:13
6285	((amorphous adj silicon) and substrate) and irradiat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:14
0	((((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and (532nm adj wavelength))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 14:48

15	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and wavelength	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:16
6	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and harmonic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:18
0	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and (third adj harmonic)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:19
0	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and harmonic and (neodymium nd)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:20
2908	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:21
302	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen with concentration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:22
45	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen with concentration)) and (halogen with concentration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 12:23
23	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen with concentration)) and (halogen with concentration)) and ((carbon and nitrogen) with concentration)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 13:16

160	("Re28385" "Re28386" "3389024" "3783049" "4059461" "4086020" "4132571" "4174217" "4226898" "4231809" "4271422" "4277884" "4300989" "4309224" "4331709" "4379020" "4409724" "4472458" "4481121" "4534820" "4544418" "4546376" "4597160" "4634473" "4735824" "4755481" "4911781" "4959247" "4959700" "4996077" "4996523" "5043224" "5075259" "5089441" "5112764" "5145808" "5147826" "5173446" "5200630" "5221423" "5225355" "5244836" "5254480" "5262350" "5262654" "5275851" "5278093" "5289030" "5296405" "5298075" "5308998" "5313075" "5352291" "5354697" "5358907" "5366926" "5387530" "5403772" "5424230" "5426064" "5470763" "5480811" "5481121" "5488000" "5492843" "5501989" "5504019" "5508207" "5508533" "5529937" "5530266" "5531182" "5534716" "5543352" "5550070" "5563426" "5569610" "5569936" "5580792" "5580815" "5585291" "5589694" "5595923" "5595944" "5604360" "5605846" "5606179" "5608232" "5612250" "5614426" "5614733" "5616506" "5619044" "5620910" "5621224" "5624851" "5637515" "5639698" "5643826" "5646424" "5654203" "5656825" "5661311" "5663077" "5677549" "5684317" "5684365" "5686328" "5686329" "5693541" "5693959" "5696003" "5696386" "5696388" "5700333" "5705829" "5712191" "5717224" "5734179" "5744822" "5744824" "5756364" "5763899" "5766977" "5773327" "5773846" "5773847" "5786796" "5795795" "5808321" "5811327" "5818076" "5821138" "5821560" "5824574" "5828429" "5838508" "5843225" "5846857" "5849611" "5882960" "5888858" "5895933" "5899547" "5929464" "5933205" "5940732" "5962869" "5963278" "5985740" "5990491" "5990542" "6005648" "6011277" "6013929" "6048758" "6063654" "6077731" "6093934" "6100562").PN.	USPAT	2002/10/31 12:57
69	("3848104" "4046618" "4059461" "4083272" "4160263" "4234358" "4249960" "4309225" "4328553" "4341569" "4370175" "4409724" "4439245" "4463028" "4468551" "4469551" "4545823" "4734550" "4764485" "4803528" "4835704" "4862227" "4937618" "4956549" "4970366" "5145808" "5217921" "5219786" "5221365" "5313076" "5352291" "5372836" "5413958" "5424244" "5448582" "5477073" "5504020" "5508209" "5523257" "5543636" "5561081" "5576556" "5578520" "5580801" "5608232" "5608251" "5612251" "5622814" "5623157" "5643801" "5648277" "5681759" "5696003" "5708252" "5712191" "5719065" "5739549" "5756364" "5804878" "5891764" "5891766" "5939731" "5943354" "5945711" "5953597" "5956105" "5962869" "5962872" "5962897").PN.	USPAT	2002/10/31 13:14
6	((("4330363") or ("4599133")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 13:16
6	((((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and (second adj harmonic)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 14:38
2	("5589406").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 14:39
0	((("5589406").PN.) and "532"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 14:39

24	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 14:46
2	((amorphous adj silicon) and substrate) and (irradiat\$4 with (cw adj laser))) and "532"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:09
4096	((amorphous adj silicon) and substrate) and irradiat\$4) and (hydrogen oxygen carbon halogen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:14
2351	((amorphous adj silicon) and substrate) and irradiat\$4) and (hydrogen oxygen carbon halogen)) and concentration	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:34
696	((amorphous adj silicon) and substrate) and irradiat\$4) and (hydrogen oxygen carbon halogen)) and concentration) and @ay<1995	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:14
1882	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen oxygen carbon halogen)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:13
1263	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen oxygen carbon halogen)) and concentration	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:15
243	((amorphous adj silicon) and substrate) and (irradiat\$4 with laser)) and (hydrogen oxygen carbon halogen)) and concentration) and @ay<1995	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:15
1259	((amorphous adj silicon) and substrate) and irradiat\$4) and hydrogen and oxygen and carbon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:14
961	((amorphous adj silicon) and substrate) and irradiat\$4) and hydrogen and oxygen and carbon) and concentration	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:15
311	((amorphous adj silicon) and substrate) and irradiat\$4) and hydrogen and oxygen and carbon) and concentration) and @ay<1995	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:22
116	((amorphous adj silicon) and substrate) and irradiat\$4) and hydrogen and oxygen and carbon) and concentration) and @ay<1995) and cm	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:24
1723	cw adj laser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:40

690	(cw adj laser) and semiconductor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/31 15:41
67	(tft and (a-silicon amorphous-silicon)) and irradiat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:32
6580	(amorphous adj silicon) and substrate and irradiat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:35
4	((amorphous adj silicon) and substrate and irradiat\$4) with harmonic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:36
258	((amorphous adj silicon) and substrate and irradiat\$4) and harmonic	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/03 16:37
67	((amorphous adj silicon) and substrate and irradiat\$4) and harmonic and (cw (continuous adj wave))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/06 09:52